Electronic Supplementary Information

Investigation of Non-Segregation Graphene Growth on Ni via Isotope-Labeled Alcohol

Catalytic Chemical Vapor Deposition

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SUPPORTING FIGURES



Fig. S1. A 17 mm×17 mm graphene film grown on a thermally evaporated Ni (250 nm) film atop a SiO₂ (50 nm)/Si substrate.



Fig. S2. Low-definition (10 μ m resolution) Raman scanning maps of an ethanol-derived graphene film transferred onto a Si/SiO₂ substrate. (a) and (b) show I_{2D}/I_G and 2D-band FWHM, respectively. Scale bars are 20 μ m.



Fig. S3. Optical transmittance of a graphene film transferred onto a quartz substrate. CVD growth time for this sample was 5 min.



Fig. S4. (a) SEM image of as-grown graphene on Ni surface with a growth time of 10 s ${}^{12}C_2H_5OH$ followed by 10s ${}^{13}C_2H_5OH$. Red arrows indicate areas of bare Ni surface. (b) A representative Raman spectrum of the sample in (a) after it was transferred to a SiO₂/Si substrate.



Fig. S5. Spot positions for Raman spectra (i)-(vi) shown in Figure 5c.